

	L #	Hits	Search Text	DBs
1	L1	10464	grating.ti,ab.	US-PGPUB; USPAT
2	L2	151007	(actuat\$4 or microactuat\$4).ti,ab.	US-PGPUB; USPAT
3	L3	97	1 with 2	US-PGPUB; USPAT
4	L4	10785	(mem\$1 or microelectromechanical\$4 or electromechanical\$4 or electro adj mechanical\$4).ti,ab.	US-PGPUB; USPAT
5	L5	163	1 and (2 or 3)	US-PGPUB; USPAT
6	L6	99932	silicon adj (monooxide or oxide) or sio	US-PGPUB; USPAT
7	L7	13	5 and 6	US-PGPUB; USPAT
8	L8	137392	sacrific\$6	US-PGPUB; USPAT
9	L9	1541	6 with 8	US-PGPUB; USPAT
10	L10	251	(2 or 4) and 9	US-PGPUB; USPAT
11	L11	3441072	(aluminum or copper or al or cu)	US-PGPUB; USPAT
12	L12	85	9 with 11	US-PGPUB; USPAT
13	L13	33	(2 or 4) and 12	US-PGPUB; USPAT
14	L14	3194	430/314,319,321.ccls.	US-PGPUB; USPAT
15	L15	1657	216/13,24.ccls.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
16	L16	158	1 and (14 or 15)	US-PGPUB; USPAT
17	L17	4	16 and 9	US-PGPUB; USPAT
18	L18	3	(14 or 15) and 5	US-PGPUB; USPAT
19	L19	21	huang-long\$.in.	US-PGPUB; USPAT
20	L20	38	kuo-yao\$.in.	US-PGPUB; USPAT
21	L21	57	19 or 20	US-PGPUB; USPAT
22	L25	125	1 and 4	US-PGPUB; USPAT
23	L28	21	25 and 6	US-PGPUB; USPAT
24	L29	14	28 not 7	US-PGPUB; USPAT
25	L30	30634	(bake or baked or baking or postbak\$4 or cure or cured or curing or postcur\$4) with (resist or photoresist or photosensitiv\$8 or photopolymer\$8 or (light or uv or ultraviolet or photo) near3 (polymer or polymeriz\$6 or polymeris\$6 or sensitiv\$6))	US-PGPUB; USPAT
26	L31	1	1 and (2 or 4) and 30	US-PGPUB; USPAT
27	L32	404	(2 or 4) and 30	US-PGPUB; USPAT
28	L33	1147723	releas\$4	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
29	L34	1692	(6 or 8 or 33) same 30	US-PGPUB; USPAT
30	L35	85	(2 or 4) and 34	US-PGPUB; USPAT
31	L36	2022	430/330.ccls.	US-PGPUB; USPAT
32	L38	0	(6 with 33) and 16	US-PGPUB; USPAT
33	L39	3	16 and (2 or 4)	US-PGPUB; USPAT
34	L44	2188	6 with (8 or 33)	US-PGPUB; USPAT
35	L45	0	41 and 44	US-PGPUB; USPAT
36	L41	11	1 and 36	US-PGPUB; USPAT
37	L46	15986	(bake or baked or baking or postbak\$4 or cure or cured or curing or postcur\$4) with (resist or photoresist or photosensitiv\$8 or photopolymer\$8 or (light or uv or ultraviolet or photo) near3 (polymer or polymeriz\$6 or polymeris\$6 or sensitiv\$6))	EPO; JPO; DERWE NT; IBM_TDB
38	L47	50030	grating	EPO; JPO; DERWE NT; IBM_TDB
39	L48	519021	actuat\$4 or microactuat\$4	EPO; JPO; DERWE NT; IBM_TDB

	L #	Hits	Search Text	DBs
40	L49	37284	mem\$1 or microelectromechanical\$4 or electromechanical\$4 or electro adj mechanical\$4	EPO; JPO; DERWE NT; IBM_TDB
41	L50	1	46 and 47 and (48 or 49)	EPO; JPO; DERWE NT; IBM_TDB
42	L51	817035	silicon adj (monooxide or oxide) or sio or sacrific\$6 or releas\$4	EPO; JPO; DERWE NT; IBM_TDB
43	L52	7	46 and (48 or 49) and 51	EPO; JPO; DERWE NT; IBM_TDB